



# 제 30회 한국반도체학술대회

The 30th Korean Conference on Semiconductors

2023년 2월 13일(월) ~ 15일(수) | 강원도 하이원리조트(그랜드호텔 컨벤션타워)

2023년 2월 14일(화), 09:00-10:45

Room F (스페이드 I, 6층)

## K. Memory (Design & Process Technology) 분과

### [TF1-K] Charge Trap Flash and PRAM

좌장: 권용우 교수(홍익대학교), 김수길 TL(SK 하이닉스)

TF1-K-1 09:00-09:15	<b>Analysis of Heavy Ion Induced Single-Event-Transients in Capacitorless DRAM based on a Polycrystalline Silicon Transistor</b> Sang Ho Lee, Jin Park, Geon Uk Kim, Ga Eon Kang, Jun Hyeok Heo, So Ra Jeon, and In Man Kang <i>School of Electronic and Electrical Engineering, Kyungpook National University</i>
TF1-K-2 09:15-09:30	<b>Application on Logic-in-Memory Circuit Using Floating Gate Field Effect Transistor with Tunneling Barrier</b> Sueyeon Kim <sup>1</sup> , Sangki Cho <sup>1</sup> , Insoo Choi <sup>1</sup> , Myounggon Kang <sup>2</sup> , Seungjae Baik <sup>3</sup> , and Jongwook Jeon <sup>1</sup> <sup>1</sup> Department of Electrical and Electronics Engineering, Konkuk University, <sup>2</sup> Department of Electrical and Electronics Engineering, Korea National University of Transportation, <sup>3</sup> Department of Electrical and Electronics Engineering, Hankyung University
TF1-K-3 09:30-09:45	<b>Triplet Spike-Timing-Dependent Plasticity with Gate-tunable Three-terminal IGZO-Based FET Using Charge Trapping System</b> Jae Bum Jeon, Seong-In Cho, Geunyoung Kim, and Kyung Min Kim <i>KAIST</i>
TF1-K-4 09:45-10:00	<b>Large Memory Window with High Synaptic Performance of van der Waals Heterostructure Devices based on 2D Layered Ge<sub>4</sub>Se<sub>9</sub></b> Gichang Noh <sup>1,2</sup> , Hwayoung Song <sup>2</sup> , Heenang Choi <sup>3</sup> , Mingyu Kim <sup>2</sup> , Saeyoung Oh <sup>4</sup> , Dong Yeon Woo <sup>1</sup> , Yooyeon Jo <sup>1</sup> , Eunpyo Park <sup>1</sup> , Min-kyung Jo <sup>2</sup> , Eoram Moon <sup>2</sup> , Yong-Sung Kim <sup>5</sup> , Hu Young Jeong <sup>4</sup> , Taek-Mo Chung <sup>3</sup> , Kibum Kang <sup>2</sup> , and Joon Young Kwak <sup>1,6</sup> <sup>1</sup> Center for Neuromorphic Engineering, KIST, <sup>2</sup> Department of Materials Science and Engineering, KAIST, <sup>3</sup> Thin Film Materials Research Center, KRICT, <sup>4</sup> Graduate School of Semiconductor Materials and Devices Engineering, UNIST, <sup>5</sup> Low-Dimensional Material Team, KRISS, <sup>6</sup> Division of Science and Technology, University of Science and Technology (UST)
TF1-K-5 10:00-10:15	<b>Emulation of Synaptic Behavior Using Pentagonal PdSe<sub>2</sub>-Based Flash Memory</b> Eunpyo Park <sup>1,2</sup> , Jae Eun Seo <sup>3</sup> , Gichang Noh <sup>1</sup> , Yooyeon Jo <sup>1</sup> , In Soo Kim <sup>1</sup> , Jongkil Park <sup>1</sup> , Jaewook Kim <sup>1</sup> , YeonJoo Jeong <sup>1</sup> , Suyoun Lee <sup>1</sup> , Inho Kim <sup>1</sup> , Jong-Keuk Park <sup>1</sup> , SangBum Kim <sup>2</sup> , Jiwon Chang <sup>3</sup> , and Joon Young Kwak <sup>1,4</sup> <sup>1</sup> KIST, <sup>2</sup> Seoul National University, <sup>3</sup> Yonsei University, <sup>4</sup> University of Science and Technology (UST)
TF1-K-6 10:15-10:30	<b>3차원 플래쉬 메모리의 이동도 향상을 위한 산화물 반도체 채널 도입</b> Yun Hee Lee <sup>1</sup> , Tae In Lee <sup>1</sup> , Eui Joong Shin <sup>1</sup> , Seunghyun Oh <sup>1</sup> , Sung Haeng Cho <sup>2</sup> , Chanjong Ju <sup>3</sup> , Jaeduk Lee <sup>3</sup> , and Byung Jin Cho <sup>1</sup> <sup>1</sup> School of Electrical Engineering, KAIST, <sup>2</sup> Oxide Electronics Research Team, ETRI, <sup>3</sup> Flash Product and Technology, Samsung Electronics Co., Ltd.
TF1-K-7 10:30-10:45	<b>Computational Design of Quantum-bit Memory Devices Using Electrode-driven Silicon Quantum Dot Platform</b> Hoon Ryu <i>KISTI</i>